

**Amendments to the Claims:**

The following listing of claims will replace all prior versions, and listings, of claims in the application:

1. (Previously Presented) A surface mounting type planar magnetic device wherein a lower ferrite magnetic film is formed on a substrate; a planar coil is formed on said lower ferrite magnetic film; an upper ferrite magnetic film having an opening above a terminal portion of said planar coil is formed; and an external electrode conductive with said planar coil terminal portion is formed, wherein the planar coil is composed of a Cu conductor and formed by electro plating with two-layered film comprising a film composed of a metal selected from Nb, Ta, Mo and W or alloy constituted of two or more thereof and Cu film as plating foundation.

2. (Currently Amended) A surface mounting type planar magnetic device wherein a lower ferrite magnetic film is formed on a substrate; a planar coil is formed on said lower ferrite magnetic film; an upper ferrite magnetic film having an opening above a terminal portion of said planar coil is formed; and an external electrode conductive with said planar coil terminal portion is formed, ~~wherein the planar coil is composed of a Cu conductor and~~ wherein average composition of the upper ferrite magnetic film and the lower ferrite magnetic film is  $\text{Fe}_2\text{O}_3$ : 40 to 50 mol%,  $\text{ZnO}$ : 15 to 35 mol%,  $\text{CuO}$ : 0 to 20 mol%,  $\text{Bi}_2\text{O}_3$ : 0 to 10 mol% while remainder thereof is composed of  $\text{NiO}$  and unavoidable impurity.

3. (Currently Amended) A production method of a surface mounting type planar magnetic device wherein upon production of a surface mounting type planar magnetic device wherein a lower ferrite magnetic film is formed on a substrate; a planar coil is formed on said lower ferrite magnetic film; an upper ferrite magnetic film having an opening above a terminal portion of said planar coil is formed; and an external electrode conductive with said planar coil terminal portion is formed, ~~wherein the planar coil is composed of a Cu conductor and upon~~

production of the surface mounting type planar magnetic device, a planar coil terminal is subjected to surface treatment prior to coupling of a planar coil terminal portion and an external electrode.

4. (Currently Amended) A production method of a surface mounting type planar magnetic device wherein upon production of a surface mounting type planar magnetic device wherein a lower ferrite magnetic film is formed on a substrate; a planar coil is formed on said lower ferrite magnetic film; an upper ferrite magnetic film having an opening above a terminal portion of said planar coil is formed; and an external electrode conductive with said planar coil terminal portion is formed, wherein ~~the planar coil is composed of a Cu conductor and upon~~ production of the surface mounting type planar magnetic device, an upper ferrite magnetic film is baked at a temperature of 900°C or more to 1050°C or less in the atmosphere of less than 1 vol.% in oxygen concentration after said upper ferrite magnetic film is applied.